Modification of TiO$_2$ Nanowire Arrays with Sn Doping as Photoanode for Highly Efficient Dye-Sensitized Solar Cells

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Abstract: The dye-sensitized solar cell (DSSC) is one candidate among the third-generation solar cells. The performance of most DSSCs based on TiO$_2$ photoanode was limited by the low electron mobility within TiO$_2$. To produce a much higher power conversion efficiency, Sn-doped TiO$_2$ nanowire arrays were successfully prepared using a simple hydrothermal process. It was found that Sn doping augments electron mobility well and raises the flat band potential to improve the performance of DSSCs. The power conversion efficiency ($\eta$) of a DSSC based on the reasonable Sn-doped TiO$_2$, N719 dye, platinized counter electrode and iodide/triiodide electrolyte reaches 8.75%. Furthermore, with an anatase TiO$_2$ light scattering layer, a DSSC based on the Sn-doped TiO$_2$ NWAs exhibits a remarkable power conversion efficiency of 9.43%, which is especially useful in weak light conditions.

Keywords: dye-sensitized solar cell; TiO$_2$ nanowires; Sn-doped; electron mobility; N719

1. Introduction

Replacing the badly polluting fossil energy with environment-friendly renewable energy sources is perhaps the best way to solve the global energy crisis. As well as various clean energy sources such as hydrogen, wind, geothermal and tidal energy, solar energy seems to be a good candidate to be the next generation energy source because the irradiation energy provided by the sun to the surface of the earth exceeds global energy consumption. Methods for converting solar energy into usable energy is therefore the most important research and development issue for researchers.

A solar cell based on photovoltaic (PV) technology is a way to convert solar energy into directly available electric energy [1,2]. Since the silicon-based solar cell was first designed [3], solar cells have been developing over several stages. Nevertheless, the application of the silicon-based solar cells (single or multi crystalline) is limited by complex preparation methods and high manufacturing costs. The remarkable invention of the dye-sensitized solar cell (DSSC) by Grätzel and his cooperators [4]—a photovoltaic chemical cell—has drawn much attention due to low manufacturing cost, simple manufacturing process and being environmentally friendly [5]. Over the past two decades, the power conversion efficiency of the dye-sensitized solar cell has been low compared with the silicon-based solar cell, but the DSSC is still a considerable candidate for producing a much higher power conversion efficiency at a later time [6–11].
As a rule, DSSC is a sandwich structure composed of a photoanode covered with a monolayer of dye molecules on a semiconductor surface, electrolytes and a counter electrode [12]. Much endeavor has been focused on the design or modification of the novel dyes [13], the novel types of electrolyte [14] or counter electrodes [15]. The photoanode also plays a key role in the operation of the DSSC, therefore, it is crucial to develop new photoanodes to improve the power conversion efficiency of DSSC.

Numerous semiconductor materials have been investigated for use as photoanodes in DSSCs, such as TiO$_2$ [16], ZnO [17], SnO$_2$ [18], In$_2$O$_3$ [19]. Among these semiconductor materials, most researchers employed TiO$_2$ nanomaterials as the photoanode of DSSCs owing to its excellent physical and chemical properties such as having a suitable isoelectric point for dye absorption, proper energy band structure for charge injection from dye molecules, well passivity to photo corrosion [20–23], and appropriate electronic orbit for reducing probability of photogenerated charges recombination [24]. In a general way, tetragonal anatase and rutile TiO$_2$ are commonly applied in DSSCs, and rutile is the most stable crystalline phase of TiO$_2$. The relatively lower electron mobility of rutile TiO$_2$ leads to larger density of states near the conduction band minimum, which could provide additional efficient electron transfer channels to render much faster electron transfer in DSSCs based on rutile TiO$_2$ [25].

The photoanode needs the highest possible specific surface area for dye adsorption, a porous structure for complete electrolyte immersion and a fast charge mobility rate to minimize photogenerated charges loss [26]. In early research, TiO$_2$ nanoparticles (NPs) were usually used as the photoanode of DSSCs [4]. NPs can provide a very large surface area for dye adsorption due to large specific surface area, electron traps caused by massive amounts of grain boundaries still limit the further improvement of the performance of DSSCs [27–32]. Extensive efforts to overcome this disadvantage have been focused on the preparation of single-crystal one-dimensional (1D) nanostructures such as nanorods (NRs), nanowires (NWs), nanotubes (NTs) and nanobelts (NBs) [33–36]. Compared with NPs film, single-crystal 1D nanostructures could provide direct carrier transport pathways to the external circle, which would increase the charge carrier collection. There are fewer defects in single-crystal 1D nanostructures of high crystallization quality, which decrease the recombination of the photogenerated carriers in the photoanode [37,38]. Among these nanostructures, rutile TiO$_2$ nanowire arrays (NWAs) are considered because they maintain the advantages of one-dimensional nanomaterials, while the large specific surface area can load more dye molecules.

Low electron mobility hampers the application of rutile TiO$_2$ NWAs in DSSCs. Doping elements is a practical method for optimizing the TiO$_2$ NWAs. Doping elements could shift the flat-band potential, decrease the recombination rate of photogenerated carriers and increase the speed of electron transport, but the choice of doping elements is predominant for the performance of DSSCs. Various elements of doped TiO$_2$ nanostructures have been studied in DSSCs such as V [39,40], Cr [41,42], Mn [43], Fe [44], Cu [45], Zn [46–52]. However, DSSCs based on Sn-doped TiO$_2$ NWAs photoanodes have not been studied. Stannum (Sn) is a candidate for doping into the crystal lattice of rutile TiO$_2$. The crystal structure and lattice constant of Tin dioxide (SnO$_2$) are close to those of rutile TiO$_2$, so the doping would not introduce defects that would trap the photogenerated electrons. The electron mobility and band gap of SnO$_2$ is 100–200 cm$^2$ V$^{-1}$ s$^{-1}$ [53] and 3.8 eV, respectively, which are higher than those of rutile TiO$_2$ (0.1–1 cm$^2$ V$^{-1}$ s$^{-1}$ [54], 3.0 eV). It could be expected that doping Sn into rutile TiO$_2$ NWAs could well augment the electron mobility, thus decreasing the recombination possibility of photogenerated electrons at the interface of photoanode and electrolyte [55]. Compared with TiO$_2$, the lower isoelectric point of SnO$_2$ limited the loading of acidic carboxyl dye molecules [56]. So, finding a suitable doping ratio of Sn is a crucial work.

In this paper, we prepared Sn-doped TiO$_2$ NWAs using a simple hydrothermal process and then assembled DSSCs based on these photoanodes with N719 dye, platinized counter electrode and iodide/triiodide electrolyte. It was found that Sn doping augments electron mobility well and raises the flat band potential to improve the performance of DSSC. Furthermore, with an anatase TiO$_2$ light scattering layer, DSSC based on the Sn-doped TiO$_2$ NWAs exhibits a remarkable power conversion efficiency of 9.43%.
2. Results and Discussion

The preparation of pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4) is shown in the Supplementary Materials. First, we used inductively coupled plasma optical emission spectrometry to measure the ratio of Sn/Ti. With SnCl$_4$ increasing in reaction resolution, the ratio of Sn/Ti is about 5/95, 11/89, 15/85 and 21/79, respectively, consistent with the reaction resolution.

The crystalline structure and the lattice parameters were examined using X-ray diffraction (XRD, PANalytical B.V., Almelo, Holland) in the 2θ range of 30°–80°. XRD patterns of pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4) are shown in Figure 1a. The only diffraction peak of TS0 was located at 62.72° which could be indexed to the rutile phase TiO$_2$ (JCPS 21-1276) and the small half-peak width indicated single growth orientation and high crystallization quality. The (002) plane suggests that [001] orientation is the crystal preferential orientation of the hydrothermal method to prepare TiO$_2$ NWAs. No extra peaks could be explained by the uniformity of the Sn doping and the formation of the uniform solid solution. As the XRD pattern of the (002) peak was enlarged, it was noted that with the amount of Sn doping increasing, the position of the diffraction peak of TS1, TS2, TS3 and TS4 moved to a smaller angle, as shown in Figure 1b. The shift of the position of the diffraction peak means the augment of lattice parameters, which may be related to that the ionic radii of Ti ions (0.061 nm), is smaller than that of Sn ions (0.071 nm) [57].

![Figure 1. (a) X-Ray diffraction (XRD) patterns of pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4), (b) enlarged XRD patterns of pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4).](image)

Raman spectroscopy (HORIBA Jobin Yvon, Pairs, France) was employed to further analyze the spatial uniformity and variation of bonds to characterize the effect of the Sn-doping in the TiO$_2$ NWs. Figure 2a shows the Raman spectra of samples TS0, TS1, TS2, TS3 and TS4 in the range of 100–800 cm$^{-1}$. For the pure rutile TiO$_2$ (sample TS0), four typical vibrational modes were perceived for rutile TiO$_2$ around 145 cm$^{-1}$ ($B_{1g}$), 445 cm$^{-1}$ ($E_g$), 610 cm$^{-1}$ ($A_{1g}$), and 240 cm$^{-1}$ for second-order effect (SOE) [58–60]. No peaks related to SnO$_2$ were detected, also indicating the uniformity of the Sn doping and the formation of the uniform solid solution. These typical vibrational modes were comprised of Ti-O bonds and the variation of lattice parameters resulted in the opposite moving of the O atoms in the adjacent O-Ti-O bonds [61]. Apparently, their positions moved to a lower wavenumber as the contents of Sn increased. As shown in Figure 2b, the red-shift of the $B_{1g}$, $E_g$ and $A_{1g}$ mode of samples TS1, TS2, TS3 and TS4 suggested the more internal strains were caused by Sn-doping in the NWs and a smaller Hooke constant, indicating weaker Ti-O bond involvement and larger lattice parameters, consistent with the XRD results.

In order investigate the Sn-doped TiO$_2$ NWAs—a substitutional solid solution or interstitial solid solution—X-ray photoelectron spectroscopy (XPS, Thermo Fisher Scientific, Waltham, MA, USA) was used to analyze the bonding state of samples TS2. For the pure rutile TiO$_2$, the two characteristic peaks of the Ti 2p spectrum were located at 464.4 eV and 458.6 eV, which are related to Ti 2p$_{1/2}$ and 2p$_{3/2}$, respectively [62,63]. For the pure rutile SnO$_2$, the two characteristic peaks of the Sn 3d spectrum were located at 495.4 eV and 486.9 eV, which are related to 3d$_{3/2}$ and 3d$_{5/2}$, respectively [64,65]. As shown...
in Figure 3a, the fully scanned XPS spectra confirmed that the existence of Ti, Sn, and O were detected in the nanowire. As shown in Figure 3b, the peak positions of two detected peaks in the spectrum of the Ti 2p showed a small positive shift of 0.1 eV toward higher binding energy compared to the pure rutile TiO₂. Meanwhile, the peak positions of the two detected peaks in the spectrum of the Sn 3d showed a small negative shift of 0.4 eV toward lower binding energy compared to the pure rutile TiO₂, as shown in Figure 3c. Considering that the electronegativity of Ti (1.54) is a little smaller than that of Sn (1.96) vs, the small shift of binding energy is ascribed to the presence of Sn metallic ions in TiO₂ lattice bringing about parts of electrons deviating from the Ti metallic ions [66–69]. The small shift of binding energy also confirms that the Sn replaces the Ti in the TiO₂ lattice but does not embed in the lattice gap. In other words, the Sn doping is also uniform at the atomic level, which was consistent with the XRD and Raman results. The O 1s spectrum of Sample TS3 can be deconvoluted to two peaks, as shown in Figure 3d. The binding energy of O-Ti is 529.36 eV, and the binding energy of O-Sn is about 530.8 eV. One peak of the O 1s spectrum located at 529.5 eV, which suggests the formation of a Sn-O-Ti linkage in the nanowire [70]. The peak located at 531.1 eV is assigned to oxygen vacancy and the surface-adsorbed H₂O [71–73].
The microstructure and microtopography are of great significance for the performance of nanomaterials. The morphology of pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4) were examined using the field emission scanning electron microscopy (FESEM, JEOL, Akishima-shi, Tokyo, Japan). Figure 4a–e are the top-surface images of different samples, in which we can clearly observe highly uniform and ordered nanowires with square cross sections. The average square edge length of each nanowire is approximately 15 nm which means that the concentration of Sn in the reaction solution does not affect the cross sections of all samples. Figure 4f–j show cross-sectional images of different samples, indicating that the growth of nanowires is almost perpendicular to the FTO substrates. This result is consistent with the XRD result. Obviously, the thickness of the NWAs is affected by the concentration of Sn in the reaction solution. While the concentration of Sn in the reaction solution is low, the thicknesses of TS1 and TS2 are nearly the same as that of the pure TiO$_2$ NWAs (TS0, 30 μm); however, with the concentration of Sn in the reaction solution increasing, for TS3 and TS4, the thickness decreases to 26 and 20 μm, respectively. As we know, the deposition and dissolution of NWs are processes of dynamic equilibrium. Because the SnO$_2$ is more easily eroded by HCl, as the concentration of Sn in the reaction solution increases, the dissolution of NWs aggravates, leading to less thickness. Figures S1 and S2 depict the element-mapping characterization of the top-surface area and the cross section of the Sn-doped TiO$_2$ NWAs (TS2), indicating that Sn is homogeneously distributed in TiO$_2$ NWAs.

![Figure 4](image-url)

**Figure 4.** Morphological characterizations of pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4): (a–e) top-surface field emission scanning electron microscopy (FESEM) image of TS0, TS1, TS2, TS3, TS4, respectively; and (f–j) cross-sectional FESEM image of TS0, TS1, TS2, TS3, TS4, respectively.

Transmission electron microscopy (TEM, JEOL, Akishima-shi, Tokyo, Japan) and high-resolution TEM (HRTEM, JEOL Akishima-shi, Tokyo, Japan) were used to examine more detailed data about the microstructures of the Sn-doped TiO$_2$ NWAs (sample TS2). As shown in Figure 5a, the structure of the Sn-doped TiO$_2$ NWAs is porous, which helps dye loading and electrolyte penetration which is beneficial for the improvement of DSSCs. The clear lattice fringes can be found in the HRTEM image, as shown in Figure 5b. The ~0.342 nm interplanar spacing of the Sn-doped TiO$_2$ NWAs is a little more than that of pure TiO$_2$ NWAs, suggesting the formation of the Sn-doped TiO$_2$ NWAs, consistent with above results. The distribution of Sn in nanowires (sample TS2) was investigated by TEM with an electron energy loss spectrometer (EELS). As shown in Figure S3, EELS elemental mappings also indicate that the Sn is uniformly distributed among entire TiO$_2$ NWs, indicating the formation of Sn doped TiO$_2$ NWAs.

The pure TiO$_2$ nanowire arrays and Sn-doped TiO$_2$ nanowire arrays with N719 dye platinized counter electrode and iodide/triiodide electrolyte were employed as photoanodes to prepare the DSSCs. The detailed methods are shown in the Supplementary Materials. Figure 6a shows the typical current density (J)–voltage (V) curves of the as-prepared DSSCs based on the pure TiO$_2$ NWAs and Sn-doped TiO$_2$ NWAs under simulated AM1.5G sunlight with 100 mW cm$^{-2}$, and the corresponding detailed DSSC parameters are listed in Table 1. The short-circuit photocurrent density ($J_{sc}$), open-circuit
voltage ($V_{oc}$), fill factor (FF) and power conversion efficiency ($\eta$) of the DSSC based on the pure TiO$_2$ NWAs (TS0) are 13.46 mA cm$^{-2}$, 748 mV, 0.741 and 7.46%, respectively. For DSSCs based on the Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4) with an increasing doping amount of Sn, the $J_{sc}$ augments from 14.28 to 15.84 mA cm$^{-2}$ and then decreases to 8.73 mA cm$^{-2}$, meanwhile, the $V_{oc}$ gradually increased. The increased $V_{oc}$ is related to higher flat-band potentials, as shown in Figure S4 [74].

A maximum $\eta$ of 8.72% was obtained for the DSSC based on TS2 Sn-doped TiO$_2$ NWAs photoanode, which may be mostly attributed to the largest $J_{sc}$.

Figure 5. (a) Transmission electron microscopy (TEM) images and (b) High resolution transmission electron microscopy (HRTEM) image of Sn-doped TiO$_2$ NWAs (TS2).

Figure 6. (a) $J$–$V$ characteristics under an irradiance of 100 mW cm$^{-2}$ simulated AM1.5G sunlight and (b) IPCE spectra of DSSC based on pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4).

Table 1. Detailed data of $J$–$V$ characteristics DSSC based on pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4).

<table>
<thead>
<tr>
<th>Sample</th>
<th>$J_{sc}$ (mA cm$^{-2}$)</th>
<th>$V_{oc}$ (mV)</th>
<th>FF (%)</th>
<th>$\eta$ (%)</th>
<th>Dye Loading (nmol cm$^{-2}$)</th>
</tr>
</thead>
<tbody>
<tr>
<td>TS0</td>
<td>13.46</td>
<td>748</td>
<td>0.741</td>
<td>7.46</td>
<td>390.4</td>
</tr>
<tr>
<td>TS1</td>
<td>14.28</td>
<td>750</td>
<td>0.738</td>
<td>7.90</td>
<td>382.7</td>
</tr>
<tr>
<td>TS2</td>
<td>15.84</td>
<td>755</td>
<td>0.732</td>
<td>8.75</td>
<td>375.4</td>
</tr>
<tr>
<td>TS3</td>
<td>11.96</td>
<td>760</td>
<td>0.776</td>
<td>7.05</td>
<td>325.2</td>
</tr>
<tr>
<td>TS4</td>
<td>8.73</td>
<td>763</td>
<td>0.782</td>
<td>5.21</td>
<td>288.6</td>
</tr>
</tbody>
</table>

To seek the cause of the $J_{sc}$ changes, the incident photon-to-current conversion efficiency (IPCE) spectra of DSSCs based on the pure TiO$_2$ NWAs and Sn-doped TiO$_2$ NWAs was tested in the range of 350–800 nm. As shown in Figure 6b, the change trend of IPCE is consistent with that of $J_{sc}$ of DSSCs. The IPCE of the DSSC with TS2 is higher than that of DSSC with other photoanodes (TS0, TS1, TS3) over the spectra ranging from 400–800 nm. Nevertheless, the IPCE enhanced with the increasing Sn amount over the spectra ranging from 350–400 nm. For the TS3 and TS4, the lower IPCE may be due to the smaller thickness which could not load enough dye molecule and higher flat-band potentials may inhibit injection of photogenerated holes [74].
Compared with the DSSC based on pure TiO$_2$ NWAs, the enhancement in the IPCE for the DSSCs based on Sn-doped TiO$_2$ NWAs may be attributed to the light harvesting ability and photogenerated electron recombination at the interface of photoanode and electrolyte [75].

The light harvesting ability is related to the dye-uptake amounts and the light trapping by the photoanode. For the pure TiO$_2$ NWAs and Sn-doped TiO$_2$ NWAs, the dye-uptake amounts decreased from 390.4 to 288.6 nmol cm$^{-2}$ as the doping amount of Sn increased, as shown in Table 1. The dye-uptake amount is relevant to the isoelectric points of photoanode. Considering the lower isoelectric point (IEP) of SnO$_2$ is lower than that of TiO$_2$ [76], the decrease of the dye-uptake amounts could be understood. As shown in Figure S5, compared to the isoelectric point of the pure TiO$_2$ NWAs, the presence of Sn in TiO$_2$ NWAs decreases the isoelectric point from 6.4 to 5.8, which would inhibit the attachment of dye molecules with acidic carboxyl groups [77]. The smaller thickness would also decrease the dye-uptake amounts.

To make certain the effect of the Sn doping on the light trapping by the photoanode, UV-vis diffuse reflectance spectra measurement was carried out. The thickness of NWAs is so large that no light could pass through the nanowire arrays, in other words, the less reflection indicates more absorption. As shown in Figure S6a, the variation in the reflection of the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3) is regular. With the doping amount of Sn increasing, the absorption of samples is enhanced at a range of wavelengths from 300 to 400 nm. This result is consistent with the IPCE result. The reflection rate was normalized, as shown in Figure S6b, indicating absorbing edge blue shifting. The equation for calculating the optical forbidden bandwidth from the diffuse reflectance is shown in the supplementary information. As shown in Figure S6c, the optical forbidden bandwidth of samples (TS0, TS1, TS2, TS3) with the doping amount of Sn is estimated to be 2.97, 3.00, 3.01 and 3.02, respectively. The larger band gap is beneficial to increasing the light absorption range of DSSCs.

To make clear the effect of the Sn doping in TiO$_2$ NWAs on photogenerated electron recombination at the interface of photoanode and electrolyte, we measured the dark current of DSSCs based on the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4). As shown in Figure S7, the Sn could reduce the dark current of the DSSCs at a given potential, indicating that Sn doping in TiO$_2$ NWAs can inhibit the photogenerated electron recombination at the interface of the photoanode and electrolyte. The lower dark current is related to higher $V_{oc}$, which is consistent with the above results [78].

To understand how to affect the photogenerated electron recombination at the interface of the photoanode and electrolyte, the photoluminescence (PL) spectrum was used to test the separation of photogenerated electron–hole pairs [79]. Figure 7a shows the PL spectra of the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4). It is noted that the intensity of PL peaks notably decreases as the doping amount of Sn increases, indicating that Sn doping could accelerate the separation of photogenerated electron–hole pairs. This may be due to the Sn doping enhancing the electron mobility of TiO$_2$ NWAs. To further analyze charge transfer kinetics in these DSSCs, electrochemical impedance spectroscopy (EIS) is carried out under 750 mV bias in dark conditions, as shown in the inset of Figure S8. All obtained curves show two arcs in low frequency and middle frequency regions. According to previous research, the enlarged low-frequency arc implies the charge transfer resistance of the photoanode, as shown in Figure S8 [80]. Through the fitting with Z-view, the resistance of the electrode could be calculated as shown in Table S1. As the doping amount of Sn increases, the charge transfer resistance gradually decreases, which certifies that the Sn doping can effectively improve charge transfer performance. We further utilized the transient photoelectric decay technique to find out the effect of the electron lifetime ($\tau_{tpd}$) on the doping amount of Sn in the DSSCs based on the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4). As displayed in Figure 7b, the $\tau_{tpd}$ in DSSCs based on the Sn-doped TiO$_2$ (TS1, TS2, TS3, TS4) are non-negligibly higher than that of DSSC based on the pure TiO$_2$ NWAs (TS0) at a certain extracted charge. With the doping amount of Sn increasing, the $\tau_{tpd}$ augments, which is identical to the variation trend of the dark current.
Consistent with the PL results, the higher $\tau_{tpd}$ is mainly due to the Sn doping enhancing electron mobility [81–83], manifesting the noticeable suppression of the photogenerated electron recombination at the interface of the photoanode and electrolyte which contributes to higher IPCE as well as $V_{oc}$.

Figure 7. (a) Photoluminescence (PL) spectra of the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4), (b) Plots of lifetime of photoinjected electrons in the DSSCs based on the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4) as a function of charge.

Additional light scattering layer on the photoanode could effectively improve the performance of DSSC [80]. An anatase TiO$_2$ particles (WERO-4, Dyesol) layer with 5 $\mu$m thickness was used as a light scattering layer on the Sn-doped TiO$_2$ NWAs (TS2) by stencil printing, which was applied as a photoanode to prepared DSSC. As displayed in Figure 8, under a simulated AM1.5G sunlight irradiance of 100 mW cm$^{-2}$, as-prepared DSSC shows a remarkable $\eta$ of 9.26% with $J_{sc}$ of 17.28 mA cm$^{-2}$, $V_{oc}$ of 735 mV, and FF of 0.729 which is a considerably high-power conversion efficiency for DSSCs. Moreover, the inset of Figure 8 showed the IPCE spectrum of this DSSC. The enhancement of IPCE is attributed to the efficient light harvesting due to the light-scattering layer of larger particles [84]. The power conversion efficiency of weak light also attracted the attention of researchers [85], so we measured the DSSC parameters under irradiation with different light intensities, and detailed data are listed in Table 2. Under an irradiation with 20.29 mW cm$^{-2}$ light intensity, this DSSC reaches a remarkable power conversion efficiency of 9.43%.

Figure 8. $J$–$V$ characteristics of the cells based the DSSC based on the Sn-doped TiO$_2$ NWAs (TS2) with a light scattering layer under an irradiance of 100 mW cm$^{-2}$ simulated AM1.5G sunlight. The inset is its IPCE spectrum.
Table 2. Detailed photovoltaic parameters of the DSSC based on the Sn-doped TiO$_2$ NWAs (TS2) with a light scattering layer under different incident light intensities.

<table>
<thead>
<tr>
<th>$P_{in}$ (mW cm$^{-2}$)</th>
<th>$J_{sc}$ (mA cm$^{-2}$)</th>
<th>$V_{oc}$ (mV)</th>
<th>FF</th>
<th>$\eta$ (%)</th>
</tr>
</thead>
<tbody>
<tr>
<td>100</td>
<td>17.28</td>
<td>735</td>
<td>0.729</td>
<td>9.26</td>
</tr>
<tr>
<td>63.63</td>
<td>11.39</td>
<td>708</td>
<td>0.733</td>
<td>9.29</td>
</tr>
<tr>
<td>50.33</td>
<td>9.28</td>
<td>684</td>
<td>0.741</td>
<td>9.35</td>
</tr>
<tr>
<td>20.29</td>
<td>3.85</td>
<td>664</td>
<td>0.749</td>
<td>9.43</td>
</tr>
</tbody>
</table>

3. Conclusions

We have successfully produced Sn-doped TiO$_2$ NWAs using simple hydrothermal methods and have analyzed their performance as a photoanode in DSSCs. The prepared Sn-doped is 30 µm length with a square section of 15 nm average square edge length. XRD, Raman and XPS results confirmed the success of Sn doping. It is found that Sn doping augments electron mobility well and raises the flat band potential to improve the performance of DSSC. The power conversion efficiency ($\eta$) of DSSC based on the reasonable Sn-doped TiO$_2$, N719 dye, platinized counter electrode and iodide/triiodide electrolyte reaches 8.75%. Furthermore, with an anatase TiO$_2$ light scattering layer, DSSC based on the Sn-doped TiO$_2$ NWAs exhibits a remarkable power conversion efficiency of 9.43%, especially useful in the weak light conditions.

Supplementary Materials: The following are available online at http://www.mdpi.com/2073-4352/9/2/113/s1, Experimental method, Figure S1: EDS elemental mapping images of cross section of Sn-doped TiO$_2$ NWAs (TS2), Figure S2: ED$\bar{S}$ elemental mapping images of top surface of Sn-doped TiO$_2$ NWAs (TS2), Figure S3: (a) the tip region of Sn-doped TiO$_2$ NWAs (TS2). Corresponding EELS elemental mapping images for b) Sn, c) Ti, and d) O, respectively, Figure S4: Mott–Schottky plots of the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4), Figure S5: The pH-dependent zeta-potential of the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4), Figure S6: (a) The UV-vis diffusive reflectance spectra of the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3), b) normalized UV-vis diffusive reflectance spectra and (c) the plots of transforming the Kubelka–Munk function versus the energy of light, Figure S7: Dark current density–voltage of DSSCs based on the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4); Figure S8: The enlarged low-frequency arc and full scale (inset graph) Nyquist plots of the DSSCs based on the pure TiO$_2$ NWAs (TS0) and Sn-doped TiO$_2$ NWAs (TS1, TS2, TS3, TS4) measured under 750 mV bias in the dark condition; Table S1: Detailed simulative values of the charge transfer resistance from EIS spectra.

Author Contributions: F.G. and D.W. designed the experiments; S.N. and B.W. performed the experiments; S.N., Y.Z., J.W. and S.J. analyzed the data; Y.Z., J.W. and S.J. contributed analysis tools; S.N. and D.W. wrote the paper, L.Z. coordinated the overall work.

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References


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